Docket No.: 0216-0516PUS1 (Patent)

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Patent Application of:

Toshihiko OHASHI et al.

Application No.: 10/541,776

Confirmation No.: 1474

Filed:

July 08, 2005

Art Unit:

For: SILICA-CONTAINING LAMINATED

Examiner: V. CHANG

1794

STRUCTURE, AND COATING

COMPOSITION FOR USE IN FORMING A POROUS SILICA LAYER

STATEMENT OF THE SUBSTANCE OF THE INTERVIEW

Commissioner for Patents P.O. Box 1450

Alexandria, VA 22313-1450

Sir

Applicant submits the following statement on the substance of the interview held on June 16, 2010.

The description of the telephonic interview as given by the Examiner on the Interview Summary Form adequately describe the details of the telephonic interview.

Application No.: 10/541,776

If necessary, the Director is hereby authorized in this, concurrent, and future replies to charge any fees required during the pendency of the above-identified application or credit any overpayment to Deposit Account No. 02-2448.

Dated:

JUL 1 2 2010

Respectfully submitted.

John W. Bailey

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